

MEMS Seismometer

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Advanced MEMS S&T

**Sandia is a multiprogram laboratory operated by Sandia Corporation, a Lockheed Martin Company,
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Overview

- Seismic instrumentation
- MEMS/microsystems advantages
- Project timeline
 - Prototype 1 (spring/proof-mass)
 - Prototype 2 (+ miniaturized optics and locking mechanism)
 - Prototype 3 (+ force balance feedback)
- Future work

Seismic Instrumentation



Geotech KS54000
3 Channel Borehole
Seismometer



Guralp CMG3-TB
3 Channel Borehole
Seismometer



Geotech GS13
Single Channel
Seismometer



Kinemetrics STS-2
3 Channel
Seismometer

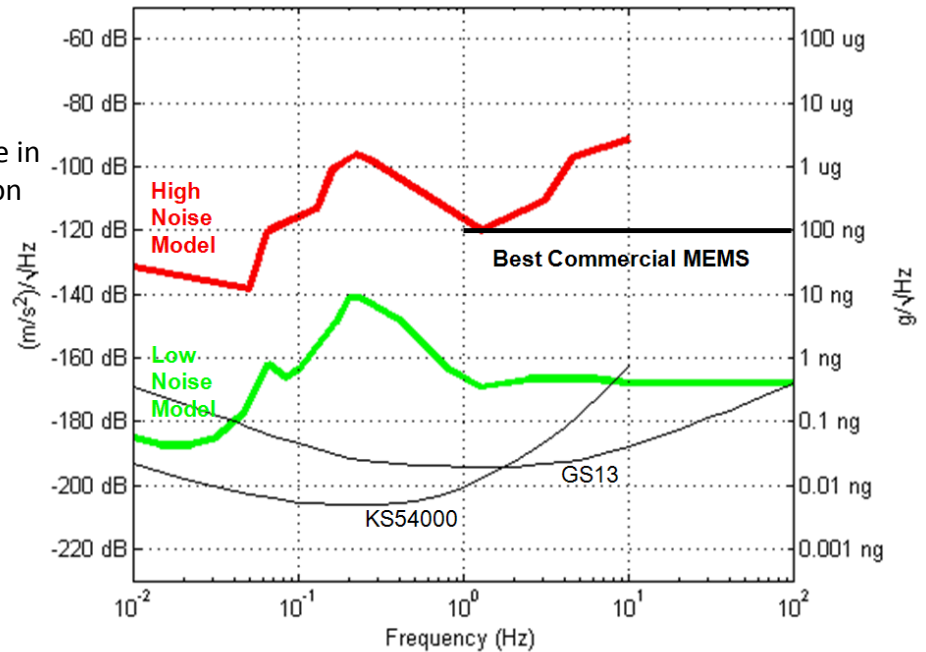


Geotech S13J
Single Channel
Seismometer



Colibrys MEMS
3 channel accelerometer
and 24 bit digitizer

Sensor noise in
acceleration



Seismic Instrumentation

- Trends in instrumentation have led to decreases in size and power at the cost of increased noise, lower sensitivity and smaller bandwidth.
- There is a large market for strong-motion sensors (seismic surveys for exploration, earthquake monitoring) - however, the market pull for high sensitivity and small seismometers is - small.

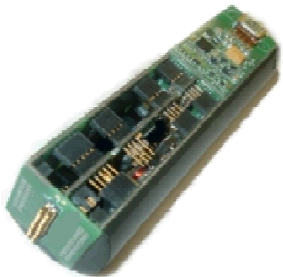
Commercial MEMS Accelerometers

There are many manufacturers of MEMS Accelerometers.

Most are targeted towards consumer, automotive, and industrial applications.

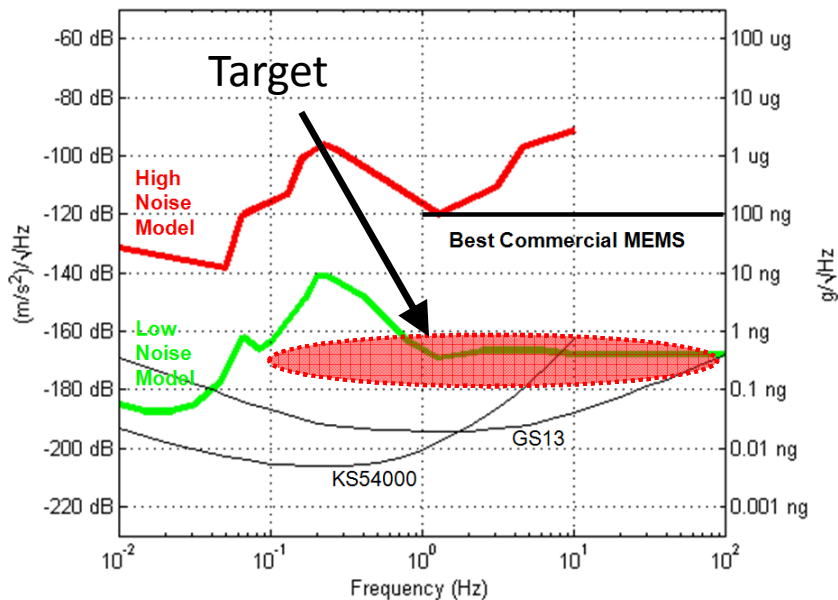
Only a few approach the noise levels necessary for strong-motion seismic applications

- Manufacturers**
- Analog Devices
 - Bosch-Sensortec
 - Colibrys*
 - Endevco*
 - Freescale
 - GeoSIG*
 - Kinematics*
 - Kionix
 - MEMSIC
 - PCB*
 - Reftek*
 - Silicon Designs
 - STMicroelectronics
 - Summit Instruments
 - Sercel*
 - Wilcoxon*
- *Noise Floor < 1 ug/VHz



Sensor Requirements

What are the desired capabilities?



	Strong Motion Seismology	Weak Motion Seismology
Noise	< 1 ug/√Hz	< 1 ng/√Hz
Bandwidth	> 1-2 Hz	SP: 0.1 Hz to 10's Hz LP: < 0.01 Hz to 1's Hz BB: 0.01 Hz to 10's Hz
Peak Acceleration	1-2 g's	< 0.25 g
Dynamic Range	~100 dB	>120 dB

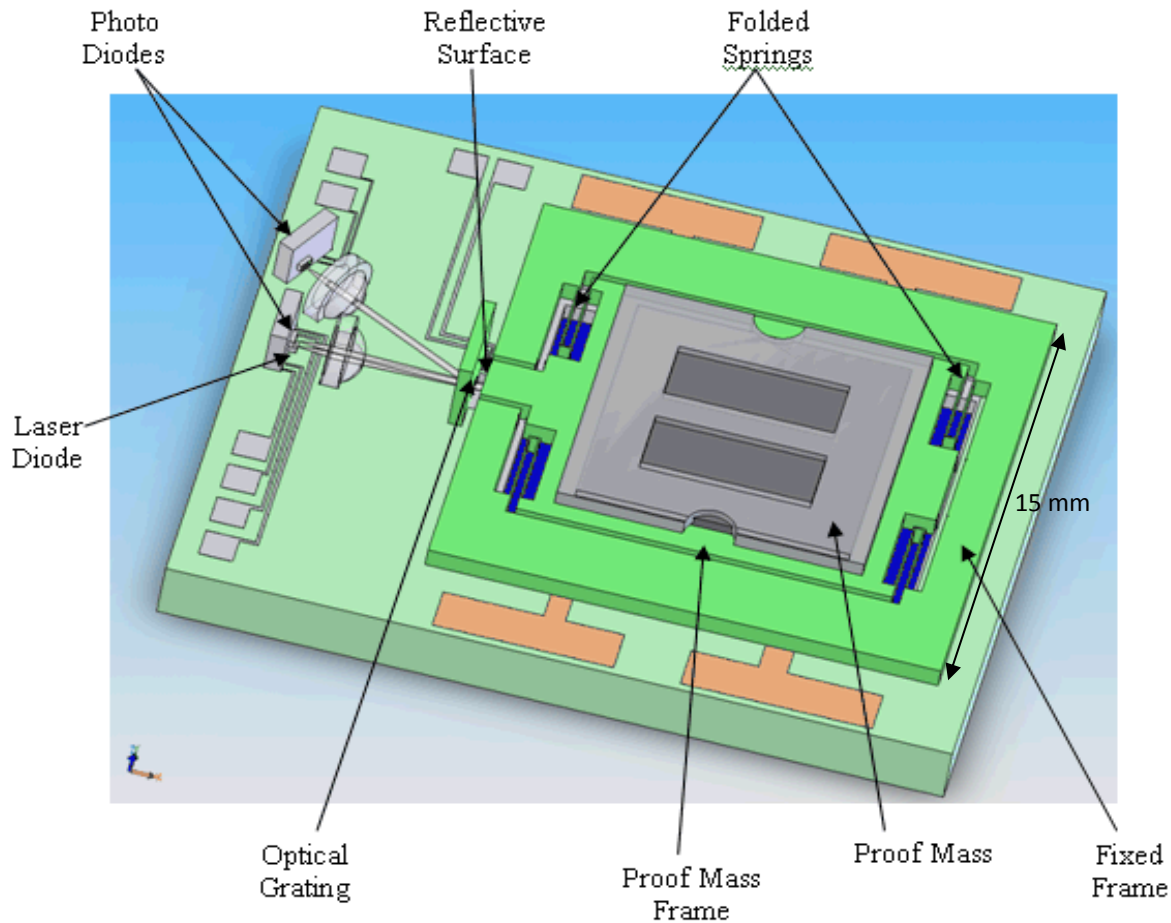
Sensor capability needs

- Self Noise Below Low Noise Model
- Dynamic Range > 120dB
- Frequency Range at least 0.2 -40 Hz
- Power Consumption < 100 mW
- Installation Flexibility
- Low Weight
- Small Size < 1 inch³
- Robustness
- Stable Response

Microsystems Advantages

- Micromachined silicon provides near-ideal (mechanical $Q \sim 10,000$), smallest dimension springs.
- Increased proof-mass with tungsten insert (~ 1 gram).
- Optical interferometric displacement detection $\sim 10^{-14}$ m (10 femtometers)/ $\sqrt{\text{Hz}}$ (proton cross-section ~ 1 fm).
- Batch fabrication of spring/proof-mass frame.

Sensor Design

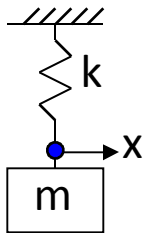


- 1 gram tungsten proof mass supported on folded silicon springs.
- Interferometric motion detection (Michelson interferometer or grating/reflector)
- Feedback control of the proof mass (magnetic).
- Theoretical self-noise of ~ 0.2 ng/ $\sqrt{\text{Hz}}$ and dynamic range greater than 120 dB using feedback control. Two primary sources of noise:
 - Mechanical
 - Electronic

Sensitivity/Noise Limits

Two physical limits

Thermomechanical noise
(harmonic oscillator)



$$a_n = \sqrt{\frac{4k_B T \omega_o}{Q \cdot m}}$$

$k_B = 1.38 \times 10^{-23} \text{ J/K}$ $T = 300\text{K}$

$\omega_o = 314.16 \text{ rad/s (50Hz)}$

$Q = 1000$ $m = 1 \text{ gram (} 10^{-3} \text{ kg)}$

$$\approx 2.3 \times 10^{-9} \text{ m / s}^2 \sqrt{\text{Hz}}$$

(~0.2ng/vHz)

Displacement detection
(optical-electronic noise)

$$\approx 10^{-14} \text{ m / } \sqrt{\text{Hz}}$$

(measured in earlier projects)

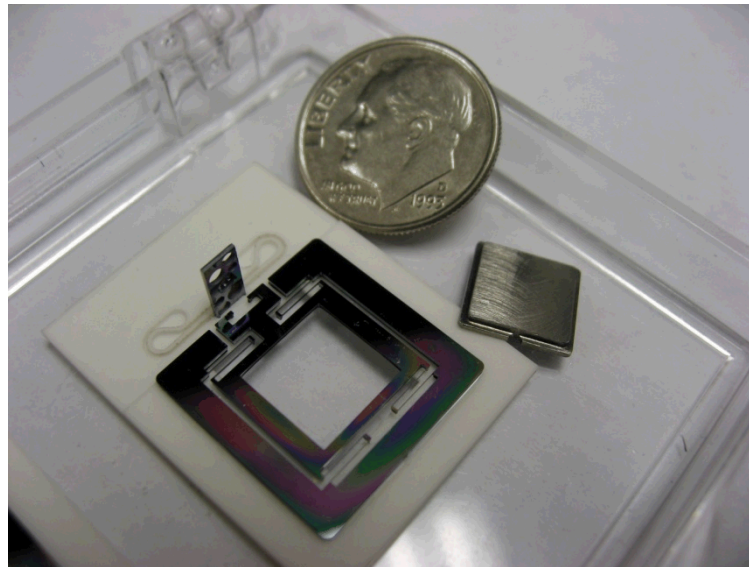
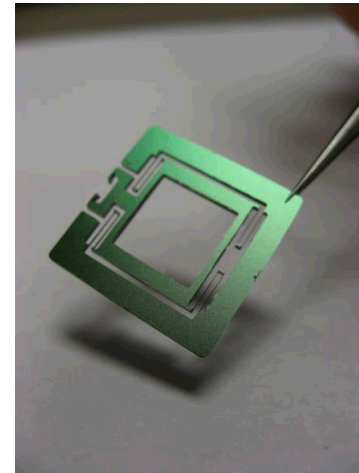
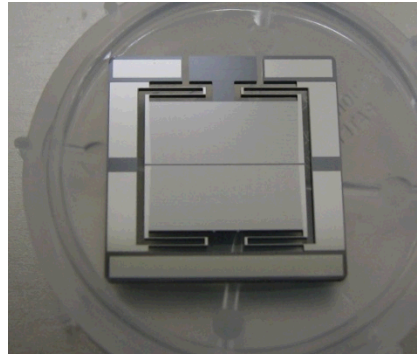
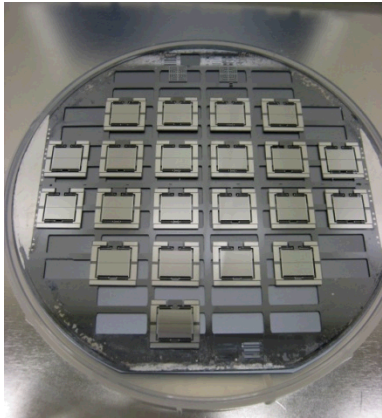
$k = 98.7 \text{ N/m}$

$k \cdot x = m \cdot a$

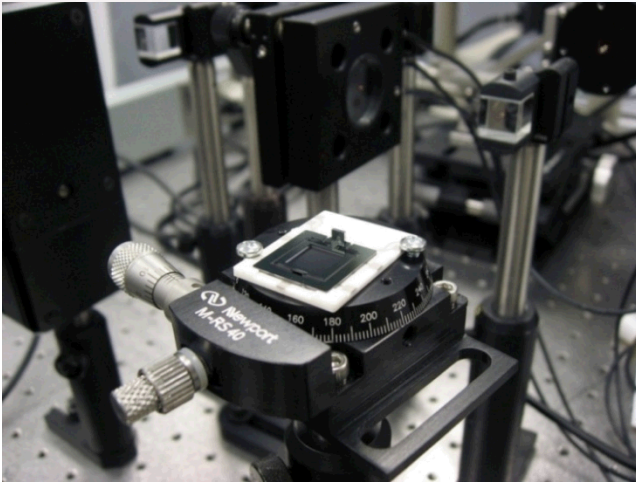
$$\approx 9.8 \times 10^{-11} \text{ m / s}^2 \sqrt{\text{Hz}}$$

(~0.01ng/vHz)

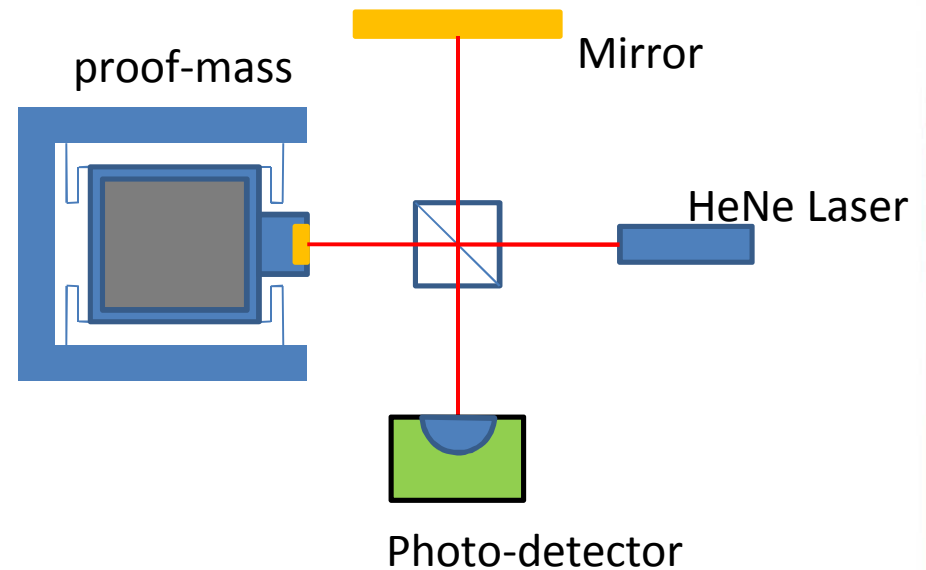
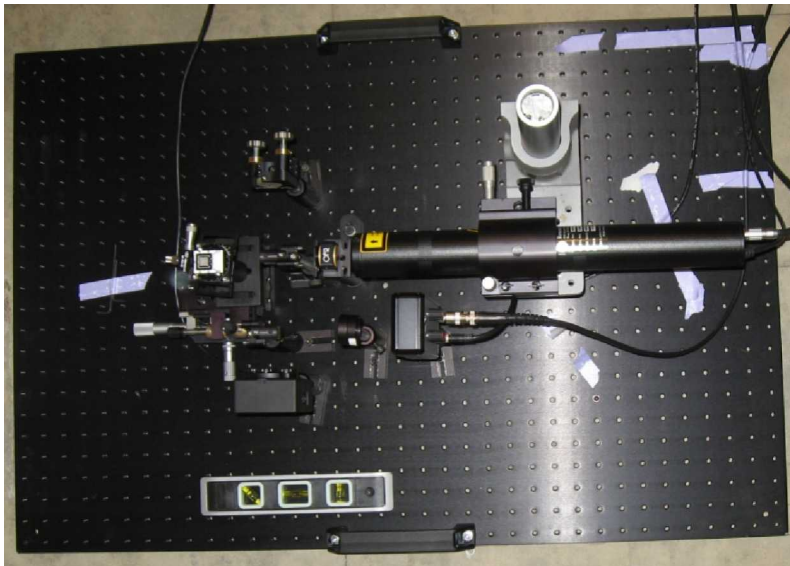
Fabricated Components



Prototype 1



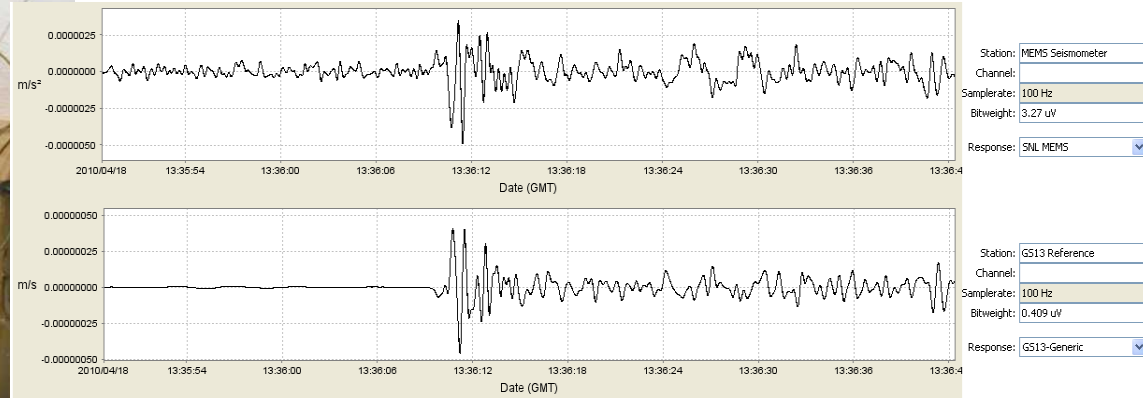
- Testing functionality of spring/proof-mass frame
- Standard optics breadboard
- Michelson interferometer setup



Prototype 1

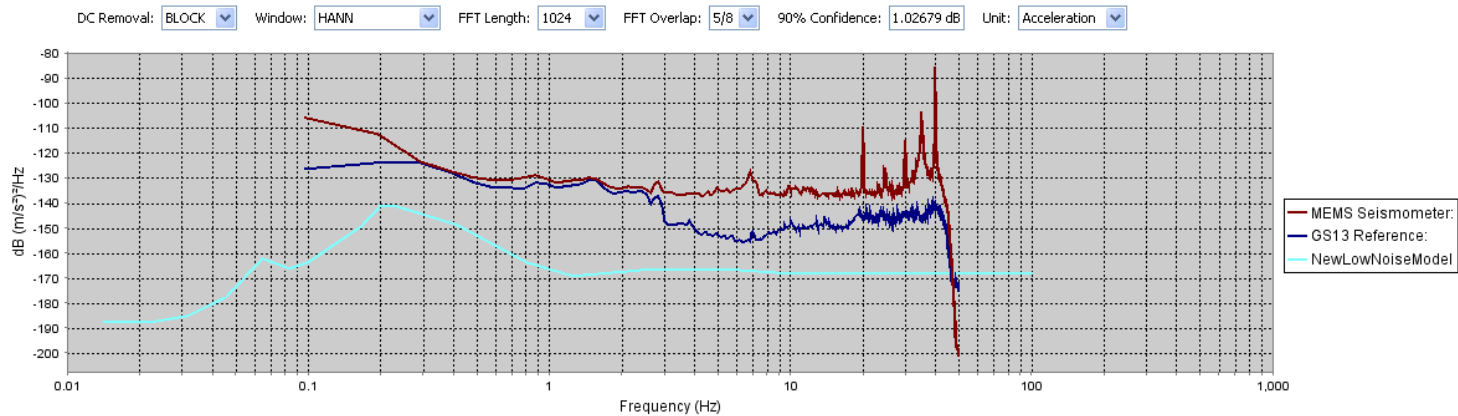
- Conducted lab tests to observe functionality and “quiet” geological test site (USGS ASL) runs to assess sensor noise floor
- Results
 - sensor self noise $\sim 12 \text{ ng}/\sqrt{\text{Hz}}$
 - sensitivity 1200 V/m/s^2
 - electronic noise $\sim 0.1 \text{ ng}/\sqrt{\text{Hz}}$

Prototype 1



Time series of the recorded seismic signal. Note that the MEMS Seismometer is shown in acceleration and the reference sensor is shown in velocity.

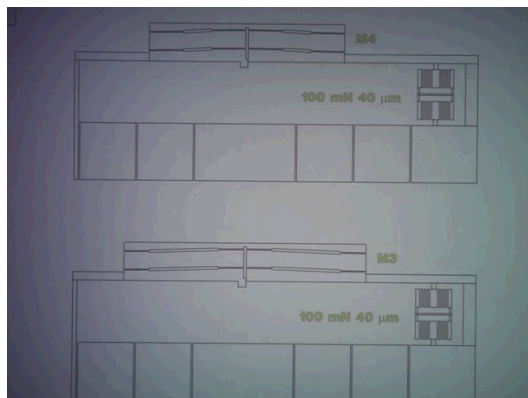
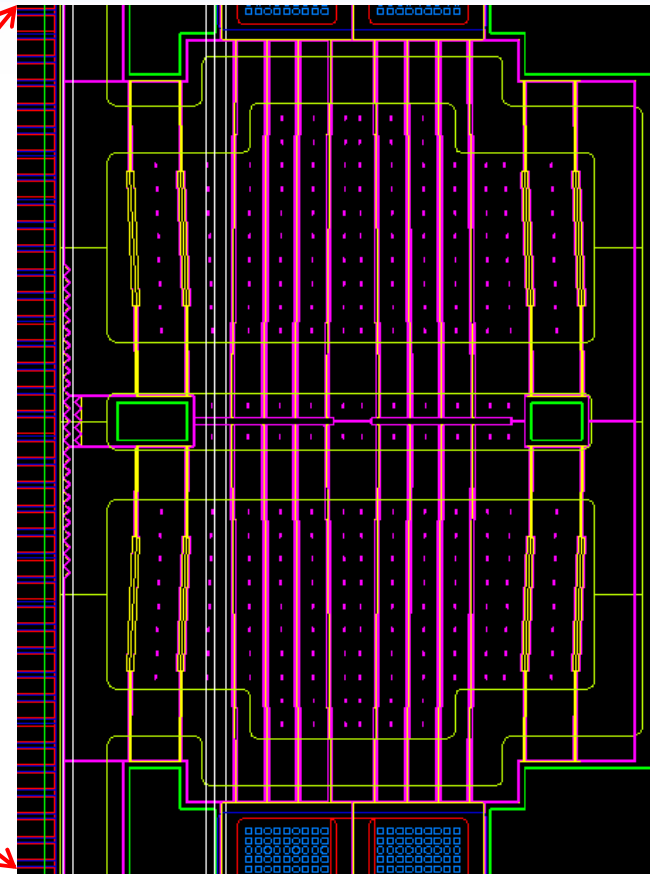
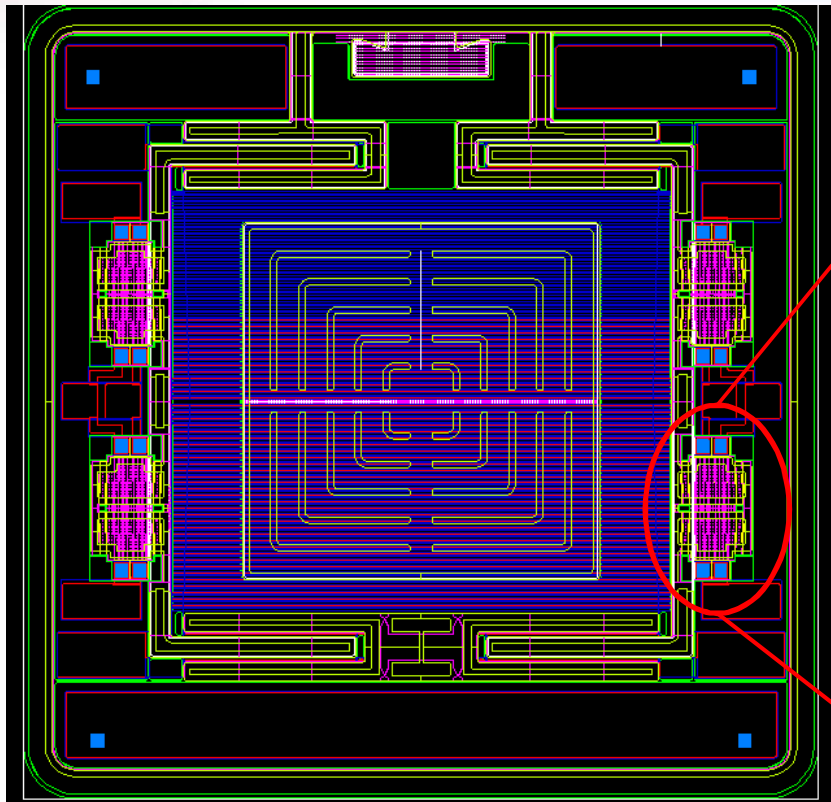
Sensitivity: $\sim 1200 \text{ V/m/s}^2$
Self Noise $\sim 12 \text{ ng/vHz}$.



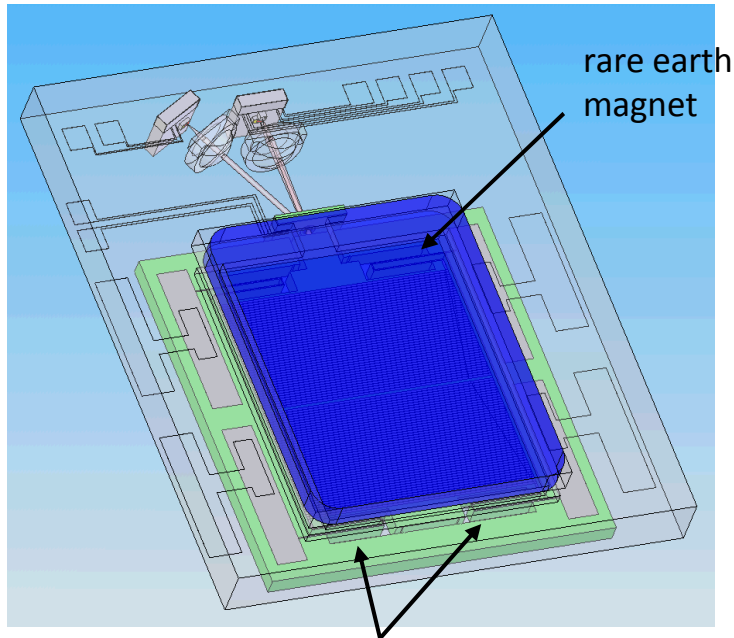
Prototype 2

- Miniaturized optical setup
 - Edge emitting laser diode (v.1)
 - VCSEL (v.2)
 - Thermally controlled micro-stage
 - Micro-assembled piezo for reference arm mirror
- Integrated MEMS locking mechanism in frame to increase robustness/fieldability

Prototype 2 – locking mechanism



Prototype 3



- Rare-earth magnet assembly and current carrying lines for force-balance feedback
 - for increased dynamic range and self-calibration during start-up and periodic checks

Future Work

- Locking mechanism and miniaturized optical test setup getting ready for testing
- Force-balance feedback setup with rare-earth magnets in fabrication
- Lab tests and quiet test site runs planned
- Goal : 1 inch-cube seismometer



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